

Method Development and Validation of Process Impurities Inritonavir Drug Substance by GCMS Technique

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Abstract: 'Quality' is the one of the important attributes, when it comes to pharmaceutical preparations. For both bulk drug industry and pharmaceutical manufactures, quality means maintaining drug standards conforming to a variety of conditions and generating profit out of it. Majority of pharmaceutical products are produced either by total synthesis approach or by altering a naturally existing product. In any case, a wide range of reactive reagents & chemicals are used. Therefore, it is accepted that trace levels of such reagents or by products are present in the final active pharmaceutical ingredient (API) or drug product as impurities. The article represents the analytical method for quantification of such process impurities from Ritonavir drug substance which is widely used as anti-retroviral agent for the treatment of HIV-AIDS. Analytical method is developed using GCMS technique. Effective validation performed as per ICH Q2 guideline suggests that the method is suitable for routine use in pharmaceutical industry.

Keywords: Ritonavir, MTV, GCMS, Process impurities

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